SiO₂/PE/Bi₂S₃核壳结构纳米颗粒的合成与性能

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摘要:以多层电解质作为微型反应器,制备了 $SiO_2/Polyelectrolyte(PE)/Bi_S_3$ 核壳纳米粒子。XRD 结果表明 Bi_2S_3 颗粒属于正交晶系。由透射电镜和场发射扫描电镜照片可知,在直径为 640~nm 左右的 SiO_2 表面覆盖了厚度 35~nm 的 Bi_2S_3 壳层。红外光谱分析结果表明硅烷网络在结构上发生了变化(SiO_2 表面的硅烷醇键沉积在 Bi_2S_3 的表面)。 SiO_2 核和 $SiO_2/PE/Bi_2S_3$ 的紫外-可见吸收光谱显示在 900~nm 存在典型吸收边。

关键词: 纳米粒子: 核壳结构: 聚电解质: 微型反应器

中图分类号: 0613.72; 0613.51; 0614.53*2 文献标识码: A 文章编号: 1001-4861(2005)09-1281-05

SiO₂/Polyelectrolyte(PE)/Bi₂S₃ Core-shell Nanoparticles: Synthesis and Properties

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Abstract: SiO_2 / Polyelectrolyte(PE) / Bi_2S_3 composite nanoparticles were prepared by a polyelectrolyte(PE) mutilayer as microreactor. Bi_2S_3 particles were shown by XRD to be with an orthorhombic uniform structure. The surfaces of SiO_2 (about 640 nm) particles were covered by thin layers (35 nm) of Bi_2S_3 consisted of 32 nm particles as evidenced by TEM and field emission scanning electron microscopic studies. The structural changes occurred in the siloxane network and surface silanol groups of SiO_2 upon the 1deposition of Bi_2S_3 . The UV-Visible spectra of SiO_2 core and SiO_2 /PE/ Bi_2S_3 show typical absorption band onset (900 nm).

Key words: nanoparticles; core-shell structure; polyelectrolyte; microreactor

0 Introduction

Semiconductor nanoparticles have been the subject of intense research during the past few years because of their potential applications in solar energy conversion, photocatalysis and the optoelectronic industry^[1-5]. Many synthetic routes have been developed so far to control the size and distribution of semiconductor nanoparticles. One of the most advanced and intriguing developments in the area of nanoparticles is the coating of semiconductor nanoparticles on a solid support to synthesize core/shell nanocomposites with

unique optical, electronic, magnetic and catalytic properties. Although the technique for coating the nanoparticles on rather large substrates is well established, coating on very small substrates, such as submicron-sized particles, remains a technical challenge. The coating of semiconductor nanoparticles on submicro-sized particles has been accomplished by using distinct chemical methods, including epitaxial growth of semiconducting phase [4], nucleation and growth inside inverse micells [5], reaction of molecular precursors [6], ultrasonic irradiation of colloidal solutions [7] and electroless deposition [8]. Other methods are also used for

收稿日期:2004-12-27。收修改稿日期:2005-04-20。

国家自然科学基金资助项目(No.20321101, No.20125103, No.90206034)。

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the preparation of a wide range of core-shell structure with controlled chemical compositions and well-defined morphological characteristics.

Nanocomposite multilayers can also be assembled on particle surface by using the layer-by-layer method based on colloidal templates. Eswarnand and Pradeep have reported a method of synthesis for zirconia coated silver clusters using self-assembled monolayers as templates^[9]. Keller and Johnson et al. have prepared alternating composite multilavers of exfoliated zirconium phosphate sheets and charged redox polymers on (3aminopropyl) triethoxysilane-modified silica particles^[10]. Olinda and co-workers have synthesized SiO₂ / Bi₂S₃ nanocomposites using single-molecule precursors [11]. Sonochemistry is also an alternative technique for the production of coated particles. Dhas and co-workers have reported the synthesis of ZnS semiconductor nanoparticles on submicron-sized silica by ultrasound irradiation near room temperature^[7]. Recently, Christina and Alfons have reported a new approach for the synthesis of colloidal gold shell particles with a dielectric core, small gold nanoclusters being attached to the functionalized surface of colloidal silica particles^[12]. In the past, efforts had been made to bind semiconductor nanoclusters to metal or inorganic surfaces using a self-assembled monolayer approach. Pastoriza-Santos and Koktysh et al. have synthesized Ag/TiO2 coreshell nanoparticles with the layer-by-layer assembly method^[13].

Recently, polyelectrolyte multiplayer shells have intrigued widespread interest as novel types of carriers and microreactors with designed properties because they exhibit controllable permeability and surface functionality^[14-16]. They have many applications in drug delivery, food and cosmetic industries or biotechnology. Shchukin and co-workers have recently synthesized smart inorganic/organic nanocomposite hollow microcapusules^[17]. In this paper we report the surface synthesis of Bi₂S₃ semiconductor nanoparticles on submicron-sized SiO₂ by the polyelectrolyte microreactor on the surface of SiO₂ colloids.

1 Experimental

1.1 Materials

Bismuth chloride, tetraethoxysilane (TEOS), ammonium hydroxide, thioacetamide (TAA), and ethanol

were purchased from Shanghai Chemical Reagent Company and used without further purification. Poly (doallyldimethylammonium chloride) (PDA), M_w = 200 000 ~370 000, Poly (sodium 4-styrensulfonate) (PSS), M_w =70 000, purchased from Aldrich. Doubly distilled water was used for the process.

Monodispersed silica spheres were prepared according to the procedure by Stöber et al. [19], *i.e.*, hydrolysis of TEOS in an ethanol solution containing water and ammonia. In a typical experiment, 2.00 g of the TEOS was added to 15 mL of absolute ethanol containing 0.16 g of distilled water, and the mixture was allowed to stand for 30 minutes. Then 5 mL of NH₃·H₂O solution (25%) was added, and the mixture was left to stand for 30 minutes. The SiO₂ colloid formed was centrifuged and washed thoroughly with water and ethanol.

The synthesized SiO₂ suspension (2 mL) mixed with a solution of citric acid (20 mL, 0.001 mol). Then an aqueous solution of PDA (1 mL, 1 mg· mL⁻¹) was added under stirring, to form a water-insoluble PDA/citrate complex on the surface of SiO₂ par-The deposition of the first PDA/citrate layer was followed by layer-by-layer assembly of polyelectrolyte PDA/PSS multiplayer using PDA (10 mL, 1 mg ·mL⁻¹) and PSS (10 mL, 1 mg·mL⁻¹) solutions . After the formation of PDA/PSS shells, the positive charge of the inner PDA layer, covered by the outer PDA/PSS shell was compensated by negatively charged citrate ions, resulting in a stable PDA/citrate complex. Exposure of PDA/citrate-PDA/PSS-SiO₂ composite particles to a solution containing 0.1 mol·L-1 NaOH would result in the rapid substitution of citrate ions to OHand the formation of PDA/OH -- PDA/PSS-SiO2 microreactors. The products was collected by centrifugation and washed with absolute ethanol.

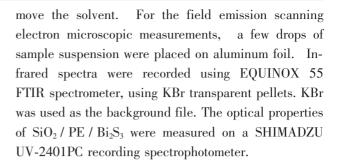
The Bi (OH)₃ nanoparticles were prepared by adding 25 mL ethanol solution of BiCl₃ to 50 mL above ethanol solution of PDA/citrate-PDA/PSS-SiO₂, 30 minutes later, the white solid was collected by centrifugation and washed thoroughly with ethanol. The white powder obtained was dried at room temperature.

Typically 0.025 g thioacetamide and 20 mL of absolute ethanol were added to a 100 mL round-bottom flask. The solution was agitated in the sonic bath

until all the thioacetamide was dissolved. Then an aliquot of white powder prepared above was added and agitated for five minutes. Then the flask was immersed in a sonic bath for several hours. The brown powders were recovered by centrifugation, washed repeatedly with absolute ethanol, and dried in vacuum.

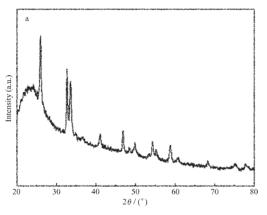
1.2 Characterization

The phase composition of the as-prepared samples were determined by X-ray diffraction, on a Rigaku (Japan) D/max-rA X-ray diffractionmeter equipped with graphite monochromatized Cu $K\alpha$ radiation (λ =0.154 06 nm). The overall morphologies of SiO₂ and SiO₂ / Bi₂S₃ were obtained by Transmission electron microscopy (TEM) using a Hitachi H-800 Transmission electron microscope (accelerating voltage =200 kV) and field emission scanning electron microscopy (FESEM) were performed on JEOL JSM-6700F. Samples for the Transmission electron microscopic measurements were obtained by placing a drop of sample suspension in absolute ethanol on a Formvar copper grid, followed by air drying period to re-



2 Results and Discussion

In Fig.1, the X-ray diffraction pattern of a typical sample shows the presence of sharp peaks, corresponding to the Bi₂S₃ crystal structure. The X-ray diffraction profile of SiO₂/Bi₂S₃ shows weak in intensity Bi₂S₃ peaks intensity, due to a small amount of Bi₂S₃. The strong background in the lower angle side is due to the presence of the SiO₂ core. The average particle sizes, calculated by the diameter of Bi₂S₃ grain t, was 32 nm at 2θ =46.85°((115) peak) using the Debye-Scherer formula t=0.89 λ /(β cos θ).



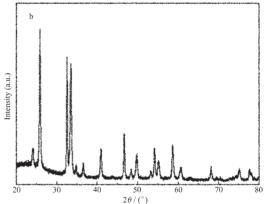


Fig.1 X-ray diffraction patterns of (a) SiO₂/PE/Bi₂S₃ and (b) Bi₂S₃

Compared to the bare SiO_2 (Fig.2a), TEM images of SiO_2 / Bi_2S_3 reveal the coating feature of the Bi_2S_3 particles. It can be seen that Bi_2S_3 is coated on the surface of SiO_2 as a thin layer. In Fig.2b, 2c, the central SiO_2 core is coated with a Bi_2S_3 layer with an average thickness about $30{\sim}35$ nm, almost without any free bare zones. From the FESEM images (Fig.3a,b), we can see that the final products have high yield (Fig.3a) and perfect spherical morphology (Fig.3b).

Infrared (IR) spectra of SiO₂ and SiO₂ / Bi₂S₃ clearly show the formation of an interfacial bond between SiO₂ and Bi₂S₃. The spectrum of SiO₂ shows three absorption bands in the region from 1 600 cm⁻¹

to 4 00 cm⁻¹, characteristic of the siloxane links. The absorption band at 460 cm⁻¹ corresponds to the rocking mode, while the band at 810 cm⁻¹ is due to the symmetric stretching of the Si-O-Si group. The observed broad doublet band in the wavenumber region of 1 300~1 000 cm⁻¹ corresponds to the asymmetric stretching vibrational mode of the Si-O-Si bridge of the siloxane link. The sharp band at 1 060 cm⁻¹ corresponds to the characteristic oxygen asymmetric stretching mode. The splitting of the asymmetric stretching mode is probably due to the presence of strained siloxane links and surface silanols (disorder-induced coupling). The IR spectrum of SiO₂ / Bi₂S₃ (Fig.4b) shows a sig-

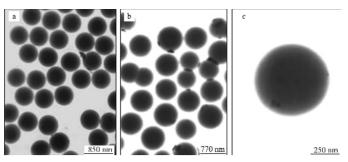


Fig.2 TEM micrographs

(a) SiO₂, (b) SiO₂/PDA/Bi₂S₃/PSS, (c) SiO₂/PDA/Bi₂S₃/PSS. (b) and (c) are lower and higher magnification.

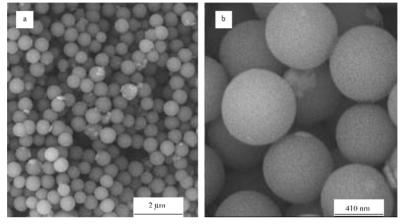


Fig.3 Field emission scanning electron microscope micrographs of SiO₂/PE/Bi₂S₃ composite nanoparticles (a) lower magnification and (b)higher magnification.

nificant change in the asymmetric stretching mode of the SiO_2 core. The doublet of the SiO_2 asymmetric stretching band is replaced by a sharp band near 1 114 cm⁻¹, corresponding to the asymmetric stretching mode and indicating a surface modification by the $\mathrm{Bi}_2\mathrm{S}_3$ coating. A 30 cm⁻¹ shift to a higher frequency is observed for the asymmetric stretching mode upon coating, probably associated with the bonding change around the [SiO₄] tetrahedral.

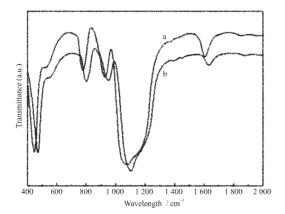


Fig.4 FTIR Spectra of (a) SiO₂ and (b) SiO₂/PE/Bi₂S₃

Fig.5 shows the UV-Visible spectra of the starting ${\rm SiO_2}$ / PE core and the final products ${\rm SiO_2}$ /PE /

 ${\rm Bi_2S_3}$ aqueous colloids. The absorption spectra of both samples are characteristic of colloidal ${\rm Bi_2S_3}$ nanoparticles the absorption band onset is closed to 900 nm, *i.e.*, slightly blue -shifted in relation to the typical bulk $E_{\rm g}$ of this semiconductor ($E_{\rm g}$ =954 nm), and extends all the way to the UV region. It is clear that the ${\rm SiO_2}$ core was covered by ${\rm Bi_2S_3}$. The UV-Visible spectrum closed to 900 nm, means that ${\rm Bi_2S_3}$ nanoparticles has been synthesized in PE microreactor.

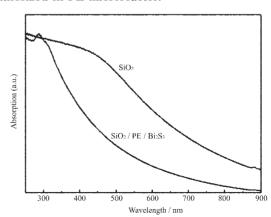


Fig.5 UV-Visible spectra of ethanol dispersions of SiO_2 and $SiO_2/PE/Bi_2S_3$

The formation of composite can be visualized be-

low, as illustrated in Fig.6: The surface of the silica particles is predominantly covered by PDA/OH⁻-PDA/PSS polyelectrolyte microreactor, when the Bi³⁺ ions was added to the system, Bi(OH)₃ was formed in the microreactor, then the Bi(OH)₃ can react with TAA under the ultrasonic irradiation and form Bi₂S₃. It is reasonable to attribute the success of our preparation to the proper deposition of polyelectrolyte layers on the surface of SiO₂ and proper anions we chose. Some other anions were used to replace the citrate acid, but cannot get desired product. The key factor is that the anions can be rapidly substituted by OH⁻. This method could be used to synthesize other new core-shell composite materials.

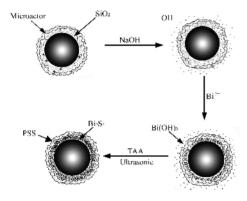


Fig.6 Schematic illustration for the formation of SiO₂/PE/Bi₂S₃ composite nanoparticles

3 Conclusions

In summary, A new approach, using the polyelectrolyte microreactor synthesis of Bi_2S_3 nanoparticles on the surface of SiO_2 colloids is suggested to construct $SiO_2/PE/Bi_2S_3$ core-shell particles with Bi_2S_3 composite shell with defined thickness. The Bi_2S_3 nanoparticles synthesized are about 32 nm in diameter. Because the coating process is the key factor and dependent on the polyelectrolyte charge and ions exchange, the shell thickness can be tuned by altering the num-

ber of polyelectrolyte layer deposited. Studies are in progress using the polyelectrolyte microreactor for preparing colloids coated with a variety of different properties and functions.

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